

## Generating quantizing pseudomagnetic fields by bending graphene ribbons

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We analyze the mechanical deformations that are required to create uniform pseudomagnetic fields in graphene. It is shown that, if a ribbon is bent in-plane into a circular arc, this can lead to fields exceeding 10 T, which is sufficient for the observation of pseudo-Landau quantization. The arc geometry is simpler than those suggested previously and, in our opinion, has much better chances to be realized experimentally soon. The effects of a scalar potential induced by dilatation in this geometry is shown to be negligible.

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### I. INTRODUCTION

Graphene exhibits a number of unique features not found in conventional metals and insulators.<sup>1,2</sup> Among them is the possibility to stretch graphene elastically by more than 15%,<sup>3</sup> and to control in different ways the induced strains.<sup>4–11</sup> This offers a prospect of tuning electronic characteristics of graphene devices not only by external electric field but also by mechanical strain,<sup>2,12</sup> a possibility being extensively discussed theoretically.<sup>12–21</sup>

The presence of two valleys at the opposite corners of graphene's Brillouin zone implies that long wavelength lattice deformations induce an effective gauge field acting on the electrons and holes, which has the opposite sign for the two valleys.<sup>1,22,23</sup> Uniaxial strains shift the origin of the two valleys from the  $K$  and  $K'$  points of the Brillouin zone in opposite directions, in an equivalent way to the effect of a constant gauge field. Nonuniform strains lead to pseudomagnetic fields.

The existence of these pseudomagnetic fields yields an enticing possibility of creating such gauge fields that would mimic a uniform magnetic field  $B$  and, consequently, generate energy gaps in the electronic spectrum and lead to a zero- $B$  analog of the quantum Hall effect.<sup>24</sup> Both isotropic and uniaxial strains result<sup>12,24</sup> in zero pseudomagnetic field  $B_S$ , but, as shown recently,<sup>24</sup> deformations with a triangular symmetry can lead to strong uniform  $B_S$ . Moreover, the strained-induced pseudomagnetic field can easily reach quantizing values, exceeding 10 T in submicron devices for deformations less than 10%.<sup>24</sup>

The generation of a nearly uniform pseudomagnetic field changes drastically the electronic states. At finite carrier concentrations, the material changes from metallic to insulating if the Fermi energy lies between Landau levels. When the chemical potential coincides with a Landau level, the electron compressibility is significantly increased, which may lead to instabilities associated to electron-electron or electron-phonon interactions.

Unfortunately, all the geometries of applied strain, which were suggested previously,<sup>24</sup> are rather difficult to realize experimentally. In this paper, we report an alternative strain configuration that does not require a complex triangular sym-

metry and, in fact, is a straightforward extension of the geometry typically used in experimental studies of strained devices.<sup>9–11</sup> We have found that simple in-plane bending of graphene ribbons (see Fig. 1) should lead to strong practically uniform  $B_S$ . We believe that this finding can speed up the observation of the pseudomagnetic quantum Hall effect and related phenomena.

### II. STRAINS AND UNIFORM PSEUDOMAGNETIC FIELDS

First, let us complete the analysis of Ref. 24 by classifying the strain distributions that are compatible with equilibrium elasticity and lead to a uniform pseudomagnetic field.

We will use the coordinates that are fixed with respect to graphene's honeycomb lattice in such a way that the  $x$  axis corresponds to a zigzag direction. In this case, the gauge field  $A$  acting on charge carriers in graphene can be written as<sup>22,23</sup>

$$A_x = \pm c \frac{\beta}{a} (u_{xx} - u_{yy}),$$

$$A_y = \mp 2c \frac{\beta}{a} u_{xy}, \quad (1)$$

where  $\beta = -\partial \log(t) / \partial \log(a) \approx 2$ , and  $t \approx 3$  eV is the electron hopping between  $p_z$  orbitals located at nearest neighbor at-

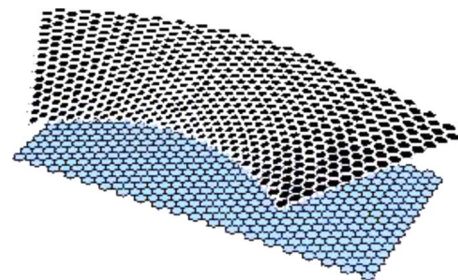


FIG. 1. (Color online) Sketch of the suggested bending geometry that would generate a uniform pseudomagnetic field and open band gaps in graphene's electronic spectrum. The graphene rectangle (lower image) is bent into a circular arc (upper).

oms,  $a \approx 1.4 \text{ \AA}$  is the distance between them,  $c$  is a numerical constant that depends on the details of atomic displacements within the lattice unit cell, and  $u_{ij}$  is the strain tensor. The two signs correspond to the two valleys,  $K$  and  $K'$  in the Brillouin zone of graphene.

In two-dimensional elasticity problems, it is convenient to study the stress tensor,  $\sigma_{ij} = \partial \mathcal{F} / \partial u_{ij}$ , where  $\mathcal{F}$  is the elastic energy.<sup>25</sup> The gauge field can be written in terms of the stress tensor as

$$\begin{aligned} A_x &= \pm c \frac{\beta}{2a\mu} (\sigma_{xx} - \sigma_{yy}), \\ A_y &= \mp c \frac{\beta}{\mu a} \sigma_{xy}, \end{aligned} \quad (2)$$

where  $\mu$  is a Lamé coefficient. Furthermore, possible stress distributions that describe two-dimensional elastic systems in equilibrium can be written in terms of complex variables  $z = x + iy$  and  $\bar{z} = x - iy$  as<sup>25</sup>

$$\begin{aligned} \sigma_{xx} &= \frac{\partial^2 f(z, \bar{z})}{\partial y^2}, \\ \sigma_{yy} &= \frac{\partial^2 f(z, \bar{z})}{\partial x^2}, \\ \sigma_{xy} &= -\frac{\partial^2 f(z, \bar{z})}{\partial x \partial y}. \end{aligned} \quad (3)$$

Here,  $f(z, \bar{z})$  is either the real or the imaginary part of a function

$$\mathcal{F}(z, \bar{z}) = \mathcal{F}_1(z) + \bar{z} \mathcal{F}_2(\bar{z}), \quad (4)$$

where  $\mathcal{F}_1(z)$  and  $\mathcal{F}_2(\bar{z})$  are analytic functions. For the case of pure shear deformations considered in Ref. 24  $\mathcal{F}_2 = 0$ , but here, we will not restrict ourselves by this limitation. Since both stress and  $A$  are given by the second derivatives of  $\mathcal{F}$ , whereas  $B_S$  is given by the first derivatives of  $A$ , a uniform  $B_S$  necessitates  $\mathcal{F}$  to have a cubic dependence on the coordinates. Such a function must have the following structure:

$$\mathcal{F}(x, y) = c_1(x + iy)^3 + c_2(x - iy)(x + iy)^2, \quad (5)$$

where  $c_1$  and  $c_2$  are arbitrary constants. Separating the real and imaginary part of Eq. (6), we find four possible functions that result in uniform  $B_S$

$$f(x, y) \propto \begin{cases} x^3 - 3xy^2 \\ x^3 + xy^2 \\ 3x^2y - y^3 \\ x^2y + y^3 \end{cases}. \quad (6)$$

The second pair of the solutions is equivalent to the first one by swapping the axes. For the lattice orientation used in Eq. (1), the first pair leads to a gauge field such that  $A_x \propto x$  and  $A_y \propto y$  and, accordingly,  $B_S$  is zero. Hence, the stress distributions that give rise to a uniform pseudomagnetic field can be expressed in terms of a superposition of the functions in lines 3 and 4. The strain configuration found in Ref. 24 in-

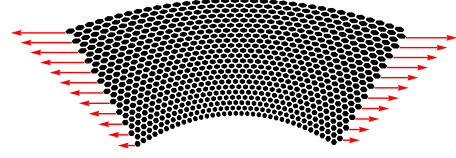


FIG. 2. (Color online) Stretching geometry leading to a uniform pseudomagnetic field inside a rectangular graphene sample. Normal forces are applied at two opposite boundaries and their magnitude is indicated by the length of the plotted arrows.

volves only the third function  $f(x, y) \propto 3x^2y - y^3$ , which leads to a unique solution for the shape of graphene flake where such distribution of stresses can be created by normal forces only. Unfortunately, this solution is not easy to realize experimentally. The use of both third and fourth functions offers further possibilities.

### III. RECTANGULAR GEOMETRY

In the following, we consider the deformations required to create a uniform  $B_S$  inside a rectangular graphene crystal, of width  $W$  and length  $L$ , with normal forces applied at the left and right boundaries as sketched in Fig. 2. The nondeformed crystal fills the region  $-L/2 \leq x \leq L/2, -W/2 \leq y \leq W/2$ . Let us write the forces at the right and left boundaries  $x = \pm L/2$  as

$$\begin{aligned} F_x^{R,L} &= f_0^{R,L} + f_1^{R,L}y, \\ F_y^{R,D} &= 0. \end{aligned} \quad (7)$$

The condition of zero total force and zero total torque requires  $f_0^R = -f_0^L = f_0$  and  $f_1^R = -f_1^L = f_1$  where  $f_0$  and  $f_1$  are constants. The absence of forces at the upper and lower edges implies that  $\sigma_{yy} = \sigma_{xy} = 0$  there. At the right and left edges, we have

$$\begin{aligned} \sigma_{xx} &= \sigma_0 \left( y + \frac{f_0}{f_1} \right), \\ \sigma_{xy} &= 0, \end{aligned} \quad (8)$$

where  $\sigma_0$  is a constant that depends on applied forces. A stress distribution within the crystal, which is compatible with these boundary conditions, is generated by a function  $f(y) = C[y^3/3 + (f_0/f_1)(y^2/2)]$ . This function can be considered as a superposition of solutions 3 and 4 of Eq. (6), which leads to a uniform  $B_S$ , and a constant term that describes a uniaxial strain and does not give rise to an additional pseudomagnetic field. The latter term ensures that the lattice is stretched everywhere, there is no possibility for out of plane deformations. Inside the rectangular crystal,  $\sigma_{xx}$  depends only on  $y$  in the manner described by Eq. (8), and  $\sigma_{yy} = \sigma_{xy} = 0$ . From this stress distribution, we find the lattice distortions

$$u_x = u_0 \left( 2xy + \frac{f_0}{f_1}x \right),$$

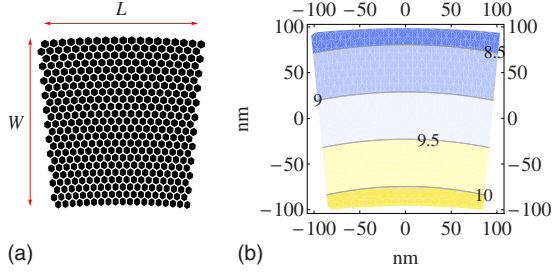


FIG. 3. (Color online) (a) Rectangular graphene sample deformed into an arc. The radii of the lower and upper edges are  $R$  and  $R+W$ , respectively. The plot is for  $R=5 \times L$ . (b) Effective magnetic field, in Teslas, for the same deformed ribbon. Dimensions are  $W=200$  nm,  $L=192$  nm, and  $R=5 \times L=960$  nm. The maximum strain is 10%.

$$u_y = u_0 \left[ -x^2 - \frac{\lambda}{\lambda + 4\mu} \left( y^2 + \frac{f_0}{f_1} y \right) \right], \quad (9)$$

where  $u_0$  is a constant that defines the maximum stress. These displacements lead to the curved shape shown in Fig. 2, which was drawn using the reported<sup>26</sup> Lamé coefficients of graphene,  $\lambda \approx 3.3$  eV  $\text{\AA}^{-2}$  and  $\mu \approx 9.4$  eV  $\text{\AA}^{-2}$ . The maximum strain occurs at the top and bottom boundaries and can be estimated as  $\bar{u}_{\max} \approx u_0(W + f_0/f_1)$ . The pseudomagnetic field inside the graphene crystal is given by

$$B_S = c\beta \frac{2\Phi_0 u_0}{a} = c\beta \frac{\Phi_0 \bar{u}}{aW}, \quad (10)$$

where  $\Phi_0$  is the flux quantum. The effective magnetic length is  $\ell_B = \sqrt{aW}/(\beta \bar{u})$ . This field has the same dependence on the crystal dimensions and the maximum strain as in the examples discussed in Ref. 24. For  $W \approx 0.1$  micron and  $\bar{u} \approx 10\%$  the generated effective field is on the order of 20 T.

Experimentally, it may be difficult to create the precise stress distribution prescribed by Eq. (8). However, one can see that the required shape of the strained graphene crystal in Fig. 2 resembles an arc of a circle. To this end, we consider next the geometry in which a rectangular graphene crystal is bent into a circular arc, as sketched in Fig. 1 and shown in more detail in Fig. 3(a). Note that this geometry is in fact standard for experimental studies of strain (see, e.g., Refs. 9–11) with the only difference that the bending should be applied in-plane rather than out-of-plane of a graphene sheet.

If the radius of the inner circle defining the lower edge in Fig. 3(a) is  $R$ , the shape of the deformed rectangle is given by

$$\begin{aligned} u_x(x, y) &= (R + y) \sin \left[ \frac{2x}{L} \arcsin \left( \frac{L}{2R} \right) \right] - x, \\ u_y(x, y) &= (R + y) \cos \left[ \frac{2x}{L} \arcsin \left( \frac{L}{2R} \right) \right] - R - y. \end{aligned} \quad (11)$$

The undistorted rectangular shape is recovered for  $L/R \rightarrow 0$ . The displacements in Eq. (11) can be expanded in powers of  $R^{-1}$ , and the leading terms are

$$\begin{aligned} u_x(x, y) &= \frac{xy}{R}, \\ u_y(x, y) &= -\frac{x^2}{2R}. \end{aligned} \quad (12)$$

These displacements do not exceed  $\max(L, W)^2/R$ . The next terms lead to corrections bound by  $\max(L, W)^3/R^2$ . The distortions in Eq. (12) coincide with those in Eq. (9) in the limit of vanishing Poisson ratio  $\lambda/(\lambda + 2\mu) \rightarrow 0$  and lead to a uniform  $B_S$  inside the sample. The maximum strain is  $L/2R$ . For an arbitrary value of  $L/R$ , the pseudomagnetic field is given by

$$\begin{aligned} B_S(x, y) &= -4c \frac{\beta \Phi_0}{aL} \arcsin \left( \frac{L}{2R} \right) \cos \left[ \frac{2x}{L} \arcsin \left( \frac{L}{2R} \right) \right] \\ &\times \left[ 1 - \frac{R+y}{L} \arcsin \left( \frac{L}{2R} \right) \right]. \end{aligned} \quad (13)$$

For  $L/R \rightarrow 0$ , the field reduces to  $B_S \approx -c(\beta \Phi_0)/(aR)$ , in agreement with Eq. (10) and the estimates given in Ref. 24. The relative corrections to the constant value of  $B_S$  are on the order  $L/2R$ , that is, the maximum strain. An example of the field distribution described by Eq. (13) is plotted in Fig. 3(b).

#### IV. SCALAR POTENTIAL

The found strain is not purely shear but it also contains a dilatation. The latter gives rise to an effective scalar potential,<sup>22</sup> in addition to the discussed pseudomagnetic field. Below, we show that due to screening, the extra potential does not radically affect Landau quantization.

Following Ref. 22 and using Eqs. (9), this potential is

$$V(x, y) = V_0 (\partial_x u_x + \partial_y u_y) = V_0 \left[ 2u_{0y} + \frac{4\mu f_0}{f_1(\lambda + 4\mu)} \right], \quad (14)$$

where  $V_0 \approx 3$  eV, estimated from the linear rise in the work function of graphene under compression between 0 and 10% strain<sup>17</sup> (note that in Ref. 22, a much larger value of 16 eV is quoted, from old experimental data on transport properties of graphite). The constant contribution gives a rigid shift to all the levels while the nonuniform term is equivalent to an effective electric field along the  $y$  direction. Unlike the strain induced gauge field, this potential will induce a charge redistribution and will be screened by the carriers in graphene.

We consider first the screening expected if we assume that the flake is a perfect metal, neglecting corrections due to quantum properties of the electron gas. The induced charge density,  $\delta\rho(\vec{r})$  can be thus obtained from the condition

$$e^2 \int d^2 \vec{r}' \frac{\delta\rho(\vec{r}')}{|\vec{r} - \vec{r}'|} = \frac{2V_0 \bar{u}}{W} \delta\rho(\vec{r})y. \quad (15)$$

This equation can be rescaled by the substitution

$$\bar{x} = \frac{x}{L},$$

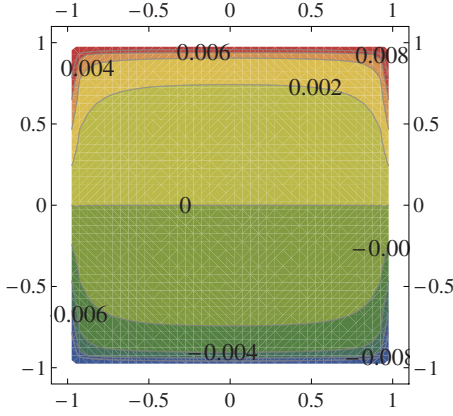


FIG. 4. (Color online) Variation in density,  $\delta\rho(\bar{x}, \bar{y})$ , in dimensionless units (see text) due to the screened scalar potential induced by strains. The aspect ratio is  $L/W=1$ .

$$\bar{y} = \frac{y}{W},$$

$$\delta\bar{\rho}\left(\frac{x}{L}, \frac{y}{W}\right) = \frac{W+L}{2L} \frac{2V_0\bar{u}}{e^2W} \delta\rho(x, y), \quad (16)$$

where the function  $\delta\bar{\rho}(\bar{x}, \bar{y})$  depends only on the aspect ratio,  $W/L$ .

The density of carriers in a given Landau level due to the effective field given in Eq. (10), setting  $c=1$ , is  $\rho_{LL} = 2(aW)/(\beta\bar{u})$  so that

$$\frac{\delta\rho(x, y)}{\rho_{LL}} = \frac{W+L}{2L} \frac{4V_0a}{\beta e^2} \delta\bar{\rho}\left(\frac{x}{L}, \frac{y}{W}\right). \quad (17)$$

Hence, the nonuniform density induced by the effective field, in units of the difference in densities between different quantum Hall plateaus, is approximately given by  $\delta\bar{\rho}$  shown in Fig. 4.

To provide an ideal metallic screening, the chemical potential should coincide at each point with the positions of one of the Landau levels. Hence, the quantum energy of the carriers is larger than in a uniform electron distribution, when the Fermi energy lies in a pseudogap between the Landau levels. Thus, in addition to the classical screening energy, discussed above, we also must add the change in energy due to the changes in occupancies of the electron levels in the presence of the scalar potential. We first assume that the induced electronic density is given by the solution of Eq. (15), and that the electronic states are the Landau levels induced by the effective field in Eq. (10). Then, the two contributions to the energy, for  $W \sim L$ , are on the order

$$E_{\text{elec}} \sim \frac{(V_0\bar{u})^2 L}{e^2} \langle |\delta\bar{\rho}| \rangle^2,$$

$$E_{\text{quantum}} \sim \frac{v_F \beta V_0 \bar{u}^2}{e^2} \langle |\delta\bar{\rho}| \rangle \sqrt{\frac{L}{a}}. \quad (18)$$

The calculations shown in Fig. 4 suggest that  $\langle |\delta\bar{\rho}| \rangle = f \approx 10^{-2} - 10^{-1}$ , and  $v_F \sim e^2 \sim V_0 a$ . Then, the scalar potential is screened, and the process can be described by the classical model outlined earlier, if  $\sqrt{L/a} \gtrsim f^{-1}$ , that is,  $L \gtrsim 10^2 - 10^3$  nm. For smaller sizes, the rigidity of the quantum levels induced by the gauge potential prevents any rearrangement of the charge inside the flake. A detailed theory of screening in this situation will be presented elsewhere. In either case, the electronic states are well described by the effective Landau levels induced by the field in Eq. (10).

## V. CONCLUSIONS

We have analyzed the strain distributions that generate uniform pseudo magnetic fields in graphene. Pseudomagnetic fields of a few Teslas can be generated in samples of hundreds of nanometers. The strain distributions also generate scalar potentials. For typical electron densities, on order  $10^{12} \text{ cm}^{-2}$ , screening suppresses the effect of the scalar potential, which does not alter the Landau level quantization induced by the pseudomagnetic field.

To create the required strain experimentally, one can think of depositing graphene ribbons onto a rectangular elastic substrate and deform it in the manner prescribed by Eq. (9) or by bending it into a circular arc (Fig. 1). Crystals rigidly attached to the substrate can then be of arbitrary shape, as the strain distribution in the substrate would project onto graphene and give rise to a (nearly) uniform  $B_S$ . Note that macroscopic substrates would require the use of rubberlike materials capable of withstanding very large strains, such that local deformations projected on a submicron graphene crystals could still reach  $\approx 10\%$ .

Besides the intrinsic interest of realizing a state with features similar to the Integer Quantum Hall Effect without a real magnetic field in graphene, the enhanced electron susceptibility induced by the strains may lead to novel interaction effects.<sup>27,28</sup> The electronic spectrum of graphene samples with wrinkles with about 10% strain show unusual features,<sup>29</sup> such as the formation of sharp resonances near the Fermi energy (see also Ref. 30), or the breaking of the symmetry between the two sublattices, which make up the lattice of graphene.

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